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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/651,679	08/29/2003	Kiyono Ikenaka	5341-16	9312
27799 7590 10/03/2007 COHEN, PONTANI, LIEBERMAN & PAVANE 551 FIFTH AVENUE			EXAMINER	
			GOMA, TAWFIK A	
SUITE 1210 NEW YORK	SUITE 1210 NEW YORK, NY 10176			PAPER NUMBER
TIEW TORRE,	141 10170		2627	
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			10/03/2007	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

ì	Application No.	Applicant(s)			
	10/651,679	IKENAKA ET AL			
Office Action Summary	Examiner	Art Unit			
· · · · · · · · · · · · · · · · · · ·	Tawfik Goma	2627			
The MAILING DATE of this communic					
Period for Reply		•			
A SHORTENED STATUTORY PERIOD FOR WHICHEVER IS LONGER, FROM THE MA - Extensions of time may be available under the provisions of after SIX (6) MONTHS from the mailing date of this communing if NO period for reply is specified above, the maximum statused for reply within the set or extended period for reply within the set or exte	ILING DATE OF THIS COMMUNION 37 CFR 1.136(a). In no event, however, may a rication. tory period will apply and will expire SIX (6) MON III by statute, cause the application to become AB	EATION. The ply be timely filed THS from the mailing date of this communication. SANDONED (35 U.S.C. § 133).			
Status					
1) Responsive to communication(s) filed					
	This action is FINAL . 2b) This action is non-final.				
3) Since this application is in condition for	3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.				
closed in accordance with the practice	e under Ex parte Quayle, 1955 C.L). 11, 100 0.0 . 210.			
Disposition of Claims		·			
4)	-98,100,101,107-111,113 and 119	n. 0-122 is/are withdrawn from consideration.			
Application Papers		·			
9)☐ The specification is objected to by the	Examiner.	houst - Evenine			
10) The drawing(s) filed on is/are:	a) accepted or b) objected to	by the Examiner.			
Applicant may not request that any object	tion to the drawing(s) be neid in abeya	g(s) is objected to. See 37 CFR 1.121(d).			
11) The oath or declaration is objected to	by the Examiner. Note the attache	ed Office Action or form PTO-152.			
·					
2. Certified copies of the priority of the certified copies of the priority of the certified copies of the certified copies of the priority of the certified copies of the certified c	documents have been received. documents have been received in of the priority documents have bee nal Bureau (PCT Rule 17.2(a)).	Application No n received in this National Stage			
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (Page 14) 3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date	Paper N	v Summary (PTO-413) o(s)/Mail Date f Informal Patent Application			

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DETAILED ACTION

This action is in response to the election filed on 7/09/2007.

Election/Restrictions

Applicant's election without traverse of Sub-Species 6 in the reply filed on 7/09/2007 is acknowledged.

Claim Rejections - 35 USC § 112

The following is a quotation of the first paragraph of 35 U.S.C. 112:

The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.

Claims 102, 103, 114 and 115 are rejected under 35 U.S.C. 112, first paragraph, as failing to comply with the enablement requirement. The claim(s) contains subject matter which was not described in the specification in such a way as to enable one skilled in the art to which it pertains, or with which it is most nearly connected, to make and/or use the invention. Applicant points to figure 19 of the specification for support of the claims, but figure 19 and its disclosure only shows a relationship between a focus beam position and an NA, and does not disclose or teach a function with respect to spherical aberration. One of ordinary skill in the art could not make and/or use the invention without undue experimentation regarding the measurement of the spherical aberration component of an unfocused beam with respect to Numerical Aperture in order to find the NA where the spherical aberration becomes discontinuous.

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Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1, 14, 102, 103, 112, 114 and 115 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shiono et al (US 6834036) in view of Arai et al (US 6870805).

Regarding claims 1 and 112, Shiono discloses an optical pickup apparatus, comprising: a first light source to emit a light flux of a wavelength λ_1 (col. 25 lines 56-63) for conducting recording and/or reproducing information for a first optical information recording medium having a protective substrate having a thickness t1 (col. 26 lines 6-15); a second light source to emit a light flux of a wavelength λ_2 ($\lambda_1 < \lambda_2$) (col. 26 lines 2-7, λ_3) for conducting recording and/or reproducing information for a second optical information recording medium having a protective substrate having a thickness t2 (t1 \ge t2) (col. 26 lines 4-7); a third light source to emit a light flux of a wavelength λ_3 ($\lambda_2 < \lambda_3$) (col. 25 lines 64-67) for conducting recording and/or reproducing information for a third optical information recording medium having a protective substrate having a thickness t3 (t2<t3) (col. 26 lines 1-2); an objective optical element into which an infinite parallel light flux comes when recording and/or reproducing information is conducted for the first, second and third optical information recording mediums (col. 6 lines 45-49); wherein the objective optical element comprises a first diffractive structure (19a fig. 8 and fig. 9); wherein a converged-light

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spot is formed on the first optical information recording medium with m-th order (m is a natural number) diffracted-light ray of the wavelength λ_1 generated by the first diffractive structure (col. 26 lines 15-23), a converged-light spot is formed on the second optical information recording medium with n-th order (n is a natural number) diffracted-light ray of the wavelength λ_2 generated by the first diffractive structure (col. 26 lines 27-31), and a converged-light spot is formed on the third optical information recording medium with k-th order (k is a natural number) diffracted-light ray of the wavelength λ_3 generated by the first diffractive structure (col. 26 lines 23-27), and wherein one of m, n and k is different from one of other two numbers (col. 26 lines 15-31).

Further regarding claims 1 and 112, Shiono fails to disclose wherein the light flux of the wavelength λ_3 which has passed an area of the objective optical element which is out of an area within NA3 becomes a flare, NA3 being a numerical aperture for the converged light spot formed on the third optical information recording medium with the light flux of the wavelength λ_3 . In the same field of endeavor, Arai discloses wherein light that passes outside of the NA3 becomes a flare (col. 44 lines 59-67 through col. 45 lines 1-22). It would have been obvious to one of ordinary skill in the art at the time of the applicant's invention to have the light outside of NA3 be a flare. The rationale is as follows: One of ordinary skill in the art would have been motivated to have the light outside the NA3 be a flare in order to have only a light of wavelength λ_3 which corresponds to NA3 used for recording of the information and to eliminate interference of other wavelengths.

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Regarding claim 14, Shiono further discloses an optical correcting structure to conduct temperature compensation and chromatic aberration compensation (col. 31 lines 36-54).

Regarding claims 102, 103, 114 and 115, Shiono discloses wherein the converged spot is formed on the third optical information recording medium (col. 26 l ines 8-33).

Arai discloses wherein the spherical aberration is discontinuous at NA3 (col. 44 lines 59-67 through col. 45 lines 1-22). It would have been obvious to have the spherical aberration be discontinuous at NA3. The rationale follows as in claims 1 and 112 above.

Regarding claims 104 and 116, Shiono further discloses wherein the first diffractive structure comprises a plurality of diffracting ring-shaped zones representing a serrated discontinuous surface (fig. 9), and at least one of the diffracting ring shaped zone comprises optical path difference furnishing structure (fig. 8 and col. 20 lines 22-39).

Claims 105, 106, 117 and 118 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shiono et al (US 6834036) in view of Arai et al (US 6870805) and further in view of Takeuchi et al (US 6807019).

Regarding claims 105, 106, 117 and 118, Shiono in view of Arai fail to disclose wherein (m, n, k) is (2,1,1), (3,2,2), (5,3,2) or (10,6,5). In the same field of endeavor, Takeuchi discloses using (3,2,2) as the orders of light (col. 9 lines 1-12). It would have been obvious to use the orders disclosed by Takeuchi. The rationale is as follows: One of ordinary skill in the art at the time of the applicant's invention would have been motivated to use the orders of light disclosed by Takeuchi in order to avoid interference

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between the lights and to achieve a high diffraction efficiency using a single diffractive element.

Further regarding claims 106 and 118, Shiono fails to disclose wherein λ_1 is between 390-420 nm, λ_2 is between 630-680 nm and λ_3 is between 750-800 nm. In the same field of endeavor, Takeuchi discloses the wavelengths claims (Table 8, col. 8). It would have been obvious to one of ordinary skill in the art at the time of the applicant's invention to use the wavelengths of Takeuchi. The rationale is as follows: One of ordinary skill in the art would have been motivated to use the wavelengths in order to have an apparatus that is compatible with CD's, DVD's and HD-DVD's.

Claims 111 and 123 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shiono et al (US 6834036) in view of Arai et al (US 6879805), and further in view of Maruyama (US 6594222).

Regarding claims 111 and 123, Shiono in view of Arai fail to disclose wherein the objective optical element comprises a different diffractive structure which is farther form the optical axis of the objective optical element than the first diffractive structure and wherein the diffractive order number of the light flux of the wavelength λ_3 having passed the different diffractive structure of the diffractive structure is different from the diffraction order number of the light flux of the wavelength λ_3 having passed the first diffractive structure. In the same field of endeavor, Maruyama discloses providing an objective element with first and second diffractive structures that are different distances from the optical axs (fig. 3a) and wherein the orders of light having passed the first diffractive structure are different than the other diffractive structure (col. 11 lines 25-54). It would have been obvious to one of ordinary skill in the art to use the diffractive

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structure of the lens disclosed by Maruyama. The rationale is as follows: One of ordinary skill in the art would have been motivated to use the diffractive structure in Maruyama in order to optimize an optical path difference function (see Maruyama col. 10 lines 30-41).

Response to Arguments

Applicant's arguments with respect to claims 1, 14, 102-16, 111, 112, 114-118 and 123 have been considered but are moot in view of the new ground(s) of rejection.

Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Tawfik Goma whose telephone number is (571) 272-4206. The examiner can normally be reached on 8:30 am - 5:00 pm.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, William Korzuch can be reached on (571) 272-7589. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/Tawfik Goma/ 9/18/2007

> /William Korzuch/ SPE, Art Unit 2627